# SYNTHESIS OF MULTIPLE-PATTERN PLANAR ANTENNA ARRAYS WITH SINGLE PREFIXED OR JOINTLY OPTIMIZED AMPLITUDE DISTRIBUTIONS 

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#### Abstract

Previous work on the generation of multiple radiation patterns by a single linear array antenna with an unchanging excitation amplitude distribution is generalized to planar arrays. The amplitude distribution common to all the excitation distributions can be prefixed or optimized jointly with the phase distributions.


## 1. INTRODUCTION

Since the size of antennas is fixed by physical considerations, the difficulty of accommodating them on satellites and other facilities with multiple antenna-based functions grows with the number of such functions if a separate antenna is used for each. In this context it is desirable for a single antenna to be able to generate multiple radiation patterns, with the excitation corresponding to each being selectable by suitable switching devices. However, it is also desirable for the various excitation patterns delivered to a multiple-pattern array antenna to have a common amplitude distribution, since implementation is technically more difficult for a variable amplitude distribution than for a variable phase distribution.

Previous papers from our group have described the synthesis of linear multiple-pattern array antennas in which the amplitude distribution common to all the excitations was prefixed so as to ensure smoothness [1] or was optimized jointly with the various excitation phase distributions [2]. In the latter case excitations were optimized directly, in the former a modified WoodwardLawson approach was used. The direct optimization method is here generalized, for both prefixed and jointly optimized amplitudes, to planar array antennas, for which the joint optimization problem has previously been approached by Bucci et al. [3] using projection operators in pattern space.

## 2. DESCRIPTION OF THE METHOD

The array factor $F(\theta, \varphi)$ of an $N \times M$ rectangular array of radiating elements laid out in the ( $x, y$ ) plane with its centre at the origin and its $m$ and $n$ axes coinciding with the $x$ and $y$ axes, respectively, is given by

$$
\begin{equation*}
F(\theta, \varphi)=\sum_{m=1}^{M} \sum_{n=1}^{N} I_{m n} \exp \left\{j k \sin \theta\left(x_{m n} \cos \varphi+y_{m n} \sin \varphi\right)\right\} \tag{1}
\end{equation*}
$$

where $I_{m n}$ is the relative excitation of the $m n$-th element (located at $\left(x_{m n}, y_{m n}\right)$ ), $k=2 \pi / \lambda$ is the wavenumber, and $\theta$ and $\varphi$ are the usual polar coordinates. Given a prefixed distribution of excitation amplitudes $\left|I_{m n}\right|$ and the required characteristics of $P$ target patterns (e.g. sidelobe levels, directivity, ripple, etc.), the excitation phase distribution corresponding to each pattern $p$ is determined using simulated annealing [4] to vary the $N M$ element phases so as to minimize a cost function constructed from the pattern specifications. For example, if only maximum sidelobe level and ripple are of interest for pattern $p$, a suitable cost function is

$$
\begin{equation*}
C_{p}=c_{p}\left(S L L_{p d}-S L L_{p}\right)^{2}+d_{p}\left(R_{p d}-R_{p}\right)^{2} \tag{2}
\end{equation*}
$$

where the first term represents the deviation of the maximum side lobe level $S L L_{p}$ from the desired level $S L L_{p d}$ in the out-of-beam region (region A in the examples shown in Fig.1), and the second does likewise for the ripple level $R_{p}$ at the top of the beam (region C in Fig.1). The constant weights $c_{p}$ and $d_{p}$ control the relative importance of the pattern quality goals.

If the excitation amplitude distribution is not prefixed but is nevertheless to be the same for all patterns, the optimization process varies the $N M$ element amplitudes and the $N M P$ phases all together. The cost function $C$ is the sum of terms like the $C_{p}$ of eq.2, and will generally also include a term or terms $C^{\prime}$ favouring the smoothness (in some sense) of the amplitude distribution so as to minimize distortion caused by mutual coupling among the elements (a term widely used for this purpose is $b\left(D R R_{d}-D R R\right)^{2}$, where $D R R$ is the dynamic range ratio $\left|I_{\max } / I_{\min }\right|$ of the excitations and $b$ is a weighting factor):

$$
\begin{equation*}
C=\sum_{p=1}^{P} C_{p}+C^{\prime} \tag{3}
\end{equation*}
$$

## 3. EXAMPLES

We consider a $16 \times 16$ square array of elements spaced $\lambda / 2$ apart in both the $x$ and $y$ directions that is required to generate a sum pattern with a beamwidth of $7.7^{\circ}$ at the level of the side lobes, a circular footprint and a square footprint (the size, location and rolloff margins of the footprints are specified in Fig.1). Because of the array size and spacing, eq. 1 becomes

$$
\begin{equation*}
F(u, v)=\sum_{m, n=-L}^{L-1} I_{m n} \exp \left\{j \frac{\pi}{2}[(2 m+1) u+(2 n+1) v]\right\} \tag{4}
\end{equation*}
$$

where $u=\sin \theta \cos \varphi, v=\sin \theta \sin \varphi$, and $L=16 / 2=8$; and because all the patterns have eight-fold symmetry, this can be further simplified to

$$
\begin{equation*}
F(u, v)=\sum_{m=1}^{L} \sum_{n=m}^{L} I_{m n} \varepsilon_{m n}\left(V_{m n}+V_{n m}\right) \tag{5}
\end{equation*}
$$

where

$$
\begin{align*}
& V_{m n}=\cos \left(\frac{(2 m-1) \pi u}{2}\right) \cos \left(\frac{(2 n-1) \pi v)}{2}\right)  \tag{6a}\\
& V_{n m}=\cos \left(\frac{(2 n-1) \pi u}{2}\right) \cos \left(\frac{(2 m-1) \pi v)}{2}\right) \tag{6b}
\end{align*}
$$

and $\varepsilon_{m n}$ is unity except when $n=m$, in which case $\varepsilon_{m m}=1 / 2$.
We present three solutions to the above problem: one in which a uniform excitation amplitude distribution is imposed; one in which the imposed amplitude distribution is obtained by sampling a Gaussian surface,

$$
\begin{equation*}
I_{m n}=\exp \left\{-0.8\left(\alpha_{m}^{2}+\beta_{n}^{2}\right)\right\} \tag{7}
\end{equation*}
$$

where $\alpha_{m}=(2 m-1) /(2 L-1), \beta_{n}=(2 n-1) /(2 L-1)$ and the coefficient 0.8 is calculated so that the dynamic range ratio is approximately 5 ; and one in which the amplitude distribution is
optimized jointly with the three phase distributions subject only to the condition that the dynamic range ratio must be less than 20 . The first two solutions were obtained using eq. 2 for the cost functions (with the ripple term omitted for the sum patterns), and the third using eq. 3 with $C^{\prime}=b\left(D R R_{d}-D R R\right)^{2}$. For each condition on the excitation amplitude distribution, the maximum sidelobe and ripple levels of the three patterns are listed in Table I (the ripple values are half the peak-to-trough differences), together with the time taken to obtain the solution using a computer with an AMD-K6-2 processor operating at 500 MHz .

Figs.2a-c show the patterns obtained when a uniform excitation amplitude distribution was imposed. Satisfactory ripple levels were obtained for the footprints ( $\pm 0.1-0.2 \mathrm{~dB}$ ), and a satisfactory sidelobe level for the sum pattern $(-21 \mathrm{~dB})$, but the condition on the excitation amplitudes is too strict to allow sidelobe levels lower than -9 dB to be achieved for the footprints. Better footprint sidelobe levels of -14 and -15 dB were attained with the Gaussian amplitude distribution without significantly affecting either the sidelobe level of the sum pattern or the ripple levels of the footprints. Fig. 3 shows the patterns obtained.

Finally, joint optimization of the excitation amplitudes and phases afforded footprints with sidelobe levels of approximately -19 or -20 dB at the cost of a rise in the sum pattern sidelobe level of only 2 dB while keeping footprint ripple below $\pm 0.25 \mathrm{~dB}$. The dynamic range ratio of the solution obtained is 14.9. Fig. 4 shows the three patterns, and Table II lists the excitation amplitudes and phases.

Note that the execution time for the joint-optimization solution was about the same as the total execution times of the prefixed-amplitude solutions, in spite of the number of simultaneously optimized quantities being four times as large. These times of course depend heavily on the
number of points at which the pattern is calculated; in this work the pattern was calculated on a grid of $60 \times 60$ points in the $(u, v)$ plane.

## 4. CONCLUSIONS

Simulated annealing can achieve the synthesis of multi-pattern planar arrays with fixed excitation amplitude distributions. The amplitude distribution may be prefixed, or optimized jointly with the pattern-specific phase distributions subject to appropriate smoothness constraints. Computations can be carried out within reasonable times on conventional desktop computers.

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## LEGENDS FOR TABLES

Table I. Sidelobe levels, ripple (half peak-to-trough distance) and computation times of each pattern obtained under each condition on the excitation amplitude distribution.

Table II. Jointly optimized excitation amplitudes and phases for the three patterns (one quadrant of the array is shown).

## LEGENDS FOR FIGURES

Fig.1. Boundaries defining the base and top perimeters of the circular (a) and square (b) footprint patterns.

Fig.2. Sum (a), circular footprint (b) and square footprint (c) patterns obtained imposing a uniform excitation amplitude distribution. $G^{\prime}(u, v)=20 \log \left(|F(u, v)| /|F(u, v)|_{\max }\right)$.

Fig.3. As for Fig.2, but for a Gaussian excitation amplitude distribution.
Fig.4. As for Fig.2, but with an excitation amplitude distribution optimized jointly with the three excitation phase distributions.

| Amplitude <br> distribution | Pattern | SLL <br> $(\mathbf{d B})$ | Ripple <br> $(\mathbf{d B})$ | Computer <br> time (s) |
| :---: | :---: | :---: | :---: | :---: |
| Uniform | Sum | -20.9 | - | 206 |
|  | Circular | -9.0 | 0.20 | 207 |
|  | Square | -9.0 | 0.11 | 222 |
|  | Sum | -20.7 | - | 169 |
|  | Circular | -14.0 | 0.20 | 178 |
|  | Square | -15.0 | 0.13 | 156 |
| Jointly Optimized | Sum | -18.8 | - | 624 |
|  | Circular | -19.2 | 0.23 |  |
|  | Square | -19.9 | 0.18 |  |

Table I


Table II


Fig.1a


Fig.1b


Fig 2a.


Fig 2b


Figs.2c


Fig.3a


Fig.3b


Fig.3c


Fig.4a


Fig.4b


Fig.4c

